

Abstract Submitted
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Spatial and pulse shape dependence of $K\alpha$ source from high contrast fs laser plasmas in regime of Relativistic Engineering LIMING CHEN, Advanced Photon Research Center, Japan Atomic Energy Agency — Interaction of intense Ti: Sapphire laser with Cu foil targets has been studied by measuring hard X-ray generation. Hard x-ray spectroscopy and $K\alpha$ X-ray conversion efficiency (η_K) from Cu plasma have been studied as a function of laser intensity via pulse duration scan ($60\text{ fs} \sim 600\text{ fs}$), laser pulse energy scan ($60\text{ mJ} \sim 600\text{ mJ}$) and target displacement scan from best focus. For intensity $I > 1 \times 10^{17}\text{ W/cm}^2$, the Cu η_K keep on increasing to reach a maximum value of 1×10^{-4} at an intensity $I = 1 \times 10^{18}\text{ W/cm}^2$. The focusing was varied widely to give a range of intensities from $10^{15}\text{ W/cm}^2 \sim 10^{18}\text{ W/cm}^2$. Two individual emission peaks are obtained, one is at best focal spot and the other is at larger target offset corresponding to $\sim 10^{15}\text{ W/cm}^2$. Each peak is corresponding to different energy absorption mechanism. In addition, when we introduce slightly detuning of compressor gratings at the best focal condition, it shows η_K generated by negatively skewed 100 fs pulse width laser irradiation reach 5×10^{-4} and almost 7 times greater than the case of positively skewed pulse. Vacuum Heating is greatly stimulated in this case and precisely control of pre-plasma is the key factor in tuning control of X-ray emission in relativistic fs regime.

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